

Form PTO-1449	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	CASE NO. 761 P3 761P7	SERIAL NO. 08/677,185 08/825360
INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)		APPLICANT Danek et al. <i>Wao et al</i>	
		FILING DATE 07/09/96 3/28/97	GROUP 1763 2814

U.S. PATENT DOCUMENTS

EXAMINER INITIAL	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

FOREIGN PATENT DOCUMENTS

	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES	NO
<i>JH</i>	0 738 002 A2	10/16/96	Europe	H01L	21/283		
<i>JH</i>	0 720 214 A2	07/03/96	Europe	H01L	21/321		
<i>JH</i>	0 545 602 A1	06/09/93	Europe	H01L	21/285		

OTHER (Including Author, Title, Date, Pertinent Pages, Etc.)

<i>TH</i>	Park et al. "A Novel A1-Reflow Process Using Surface Modification by the ECR Plasma Treatment and its Application to the 256Mbit DRAM" Semiconductor R&D Center, Samsung Electronics Co. Ltd. pp. 109-112, Dec. 11, 1994

EXAMINER <i>Quart</i>	DATE CONSIDERED 9/22/00
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.